



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :

Taku HIRAYAMA et al. :

Serial No. 10/568,951 : **Mail Stop: PCT Branch**

Filed May 5, 2006 : Attorney Docket No. 2006_0227A

MATERIAL FOR FORMING RESIST
PROTECTIVE FILM FOR LIQUID
IMMERSION LITHOGRAPHY PROCESS,
RESIST PROTECTIVE FILM FORMED BY
THE MATERIAL, AND METHOD OF FORMING
RESIST PATTERNS USING THE MATERIAL

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents

P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
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Sir:

Enclosed herewith is a copy of the Official Filing Receipt for the above-identified application marked with an arrow indicating corrections to be made thereto.

Accordingly, it is requested that the PTO issue a Corrected Filing Receipt reflecting these corrections.

Respectfully submitted,

Taku HIRAYAMA et al.

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January 9, 2008



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| APPLICATION NUMBER | FILING or 371(c) DATE | GRP ART UNIT | FIL FEE REC'D | ATTY.DOCKET.NO | TOT CLAIMS | IND CLAIMS |
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| 10/568,951 | 05/05/2006 | 1795 | 1030 | 2006-0227A | 13 | 1 |

CONFIRMATION NO. 9336

CORRECTED FILING RECEIPT

513
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SUITE 800
WASHINGTON, DC 20006-1021



Date Mailed: 12/04/2007

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections

Applicant(s)

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Assignment For Published Patent Application

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Power of Attorney: The patent practitioners associated with Customer Number 513

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/12204 08/25/2004

Foreign Applications

JAPAN 2003-300666 08/25/2003
JAPAN 2003-356963 10/16/2003

If Required, Foreign Filing License Granted: 10/29/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 10/568,951**

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No

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2nd
PAGE

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WENDEROTH, LIND & PONACK



Title

Material for forming resist-protecting film for immersion exposure process, resist-protecting film made of such material, and method for forming resist pattern using such resist-protecting film

Preliminary Class

430

resist-protecting

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Title 37, Code of Federal Regulations, 5.11 & 5.15

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